Advances in Investigations of clean Nb surfaces

G. Müller FB C Physics Department University of Wuppertal, Germany gmueller@uni-wuppertal.de

- Motivation
- Enhanced field emission of Nb surfaces
- Preparation and measurement techniques
- Statistical distribution of field emitters
- FE properties and nature of emitters
- Conclusions and outlook





Accelerating fields E_{acc} in SC Nb cavities are limited by NC defects and protrusions and surface impurities
 U

local quenches electron loading due to field emission

- Improved Nb purity and surface preparation techniques are required to achieve E_{acc}>25 MV/m at Q₀>10¹⁰ reliably
- Advanced surface investigation of clean Nb samples by profilometry, scanning FE microscopy and SEM/EDX

Identification of relevant features for field limitation

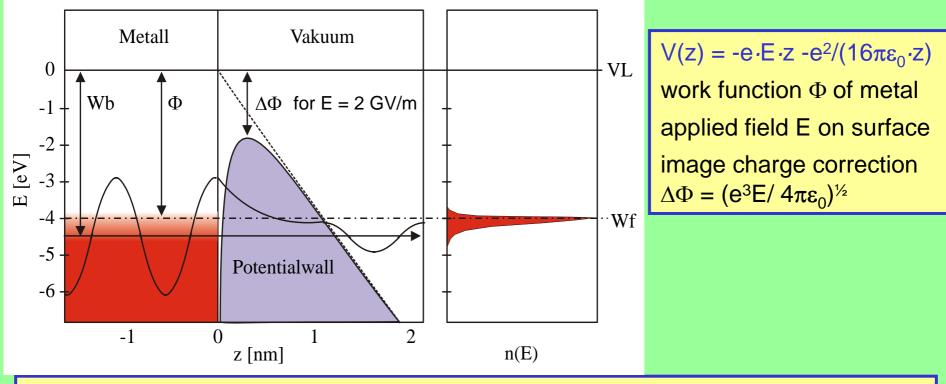
Systematic improvement and control of surface quality





Field emission of electrons from flat metal surfaces

Electron waves of bound states in a metal can tunnel through the potential barrier V(z) at the solid surface into vacuum by means of the quantum mechanical tunnelling effect



Calculation of the current density j(E) within the Fowler-Nordheim theory results in

$$j(E) = \frac{AE^2}{\Phi t^2(y)} \exp\left(-\frac{B\Phi^{3/2}v(y)}{E}\right)$$

with constants A=154 and B=6830 and slight correction functions t(y) and v(y)

 Φ =4eV at E=2000 MV/m \Rightarrow j= 1nA/µm²



Enhanced field emission of electrons from real surfaces

For real metal surfaces, i.e. broad area cathodes with some roughness and pollution, nA currents occur at much lower fields (<100 MV/m) than predicted by FN theory

modified FN theory with **field enhancement factor \beta** describes at least the slope of locally measured I(E) curves quite well:

$$I(E) = S \frac{A(\beta \cdot E)^2}{\Phi} \exp\left(-\frac{B\Phi^{3/2}}{\beta \cdot E}\right)$$

with emitting surface S as fit parameter

Theoretical models for enhanced field emission of real surfaces:

• Geometric field enhancement for metallic protrusions/rough particulates



of height h and edge radius $r_k \Rightarrow \beta \approx h/r_k$

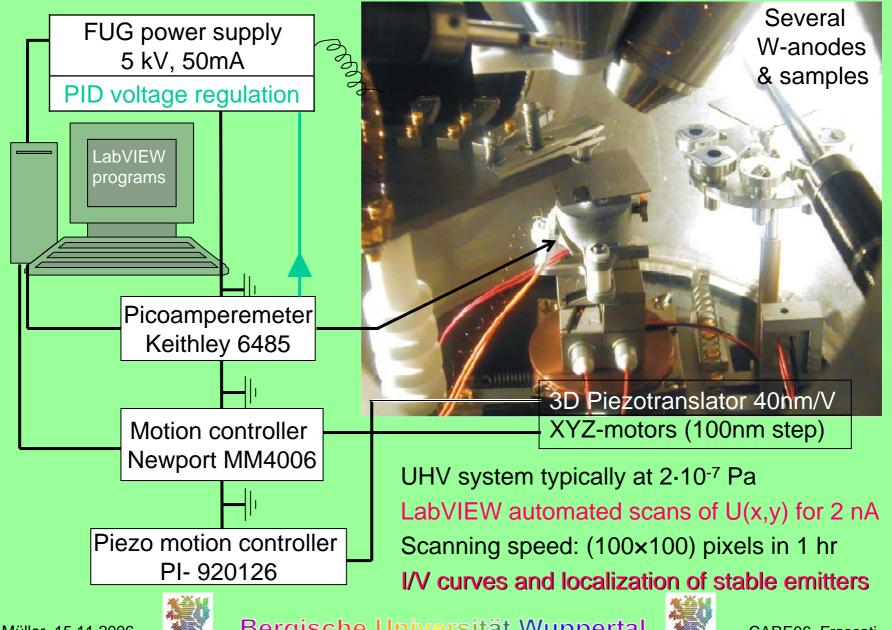
- Metal-Isolator-Vacuum for metals with oxide layers (d < 10 nm)
 ⇒ irreversible creation of conducting channels ⇒ switch-on effect
- Antenna or Metal-Isolator-Metal for particles on oxidized metals
 - after switch-on at $\beta \approx h/d$ geometric field enhancement as above
- Resonant tunneling through localized states in adsorbates and oxides

 \Rightarrow





Field emission scanning microscope (FESM)



G. Müller, 15.11.2006

Bergische Universität Wuppertal

Profilometer with AFM and SEM with EDX

Additional surface analysis of whole samples and relocalized areas of enhanced FE

Optical profilometer with lateral resolution of 2 µm and height resolution of 3 nm



combined with atomic force microscope AFM Scanning speed: (100×100) pixels in 1 min



Scanning electron microscope SEM (XL-30) with energy dispersive X-ray analysis EDX



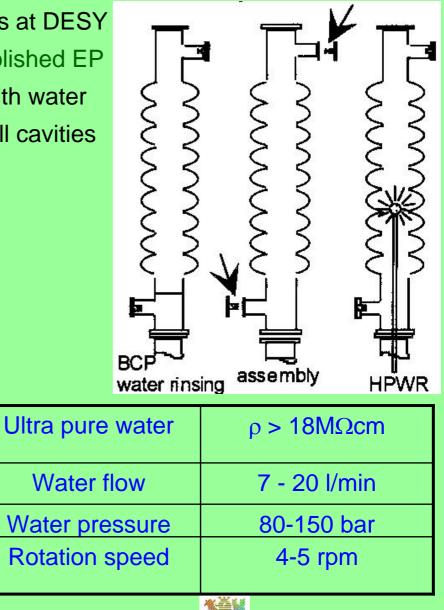
CARE06, Frascati



Preparation techniques for Nb samples

Nb samples prepared like cavities at DESY Buffered chem. BCP or electropolished EP and **high pressure rinsed HPR** with water mostly in single cells, few in 9-cell cavities





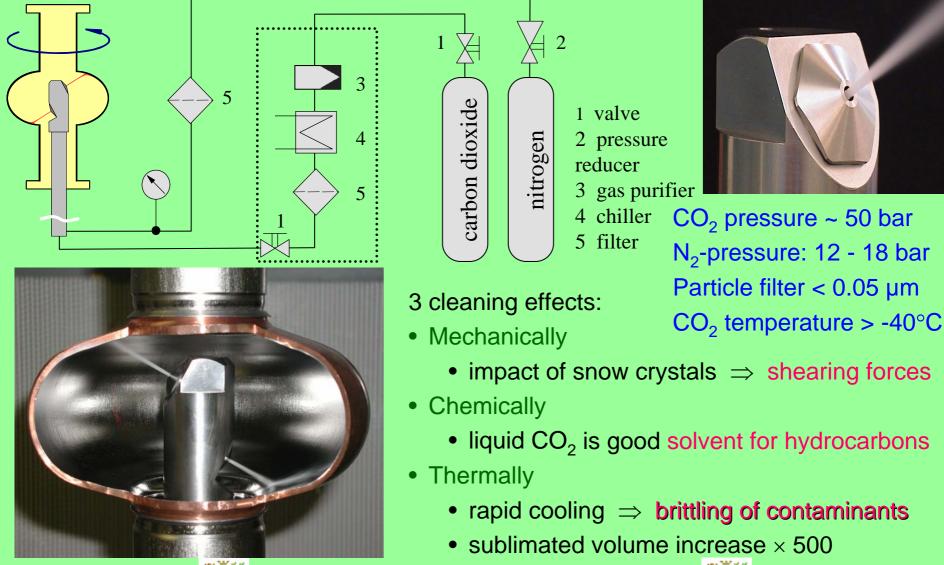
CARE06, Frascati

<u>28 mm</u>



Dry ice cleaning of Nb samples (DIC)

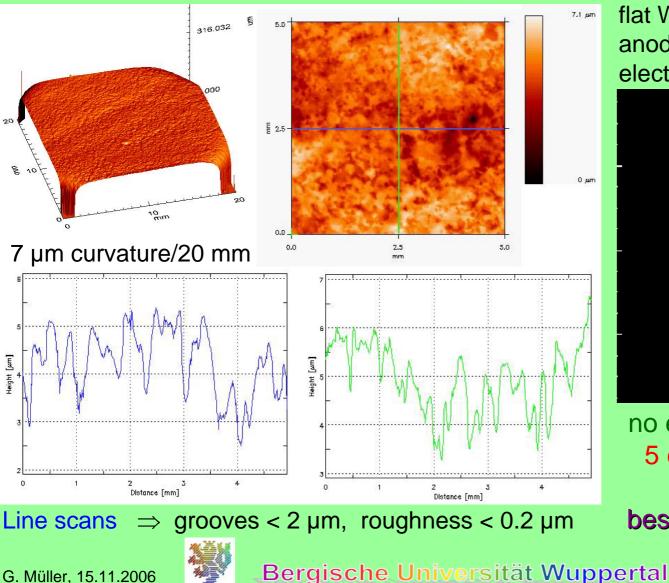
Process developed at FH Stuttgart and adapted for cavities at DESY





Quality control scans of EP/HPR-Nb prepared in 9-cell cavity

Profiles of whole sample and central part of sample scanned area $20 \times 20 \text{ mm}^2$ $5 \times 5 \text{ mm}^2$



PID-regulated U(x,y) for 1 nA scanned area = $7.5 \times 7.5 \text{ mm}^2$ flat W-anode \emptyset_a = 100 µm anode voltage U = 4800 V electrode spacing Δz = 32 µm

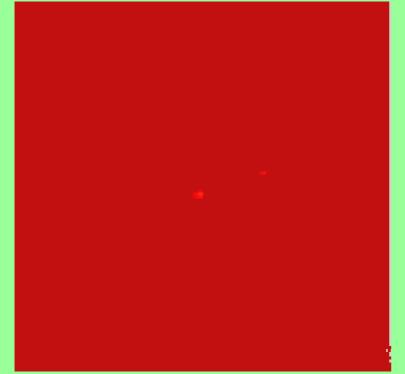


no emission @ 120MV/m 5 emitters @ 150MV/m ↓ best EP/HPR sample yet



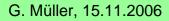
Emitter distribution on single crystal Nb after BCP/HPR

Alternative approach for mirror-like surfaces:large crystal Nb+BCP30µm/HPRPID-regulated voltage maps U(x,y) for 1 nAscanned area = $7.5 \times 7.5 \text{ mm}^2$ flat W-anode $Ø_a = 100 \text{ µm}$ anode voltage U = 4800 Velectrode spacing $\Delta z = 32 \text{ µm}$ $\Delta z = 24 \text{ µm}$



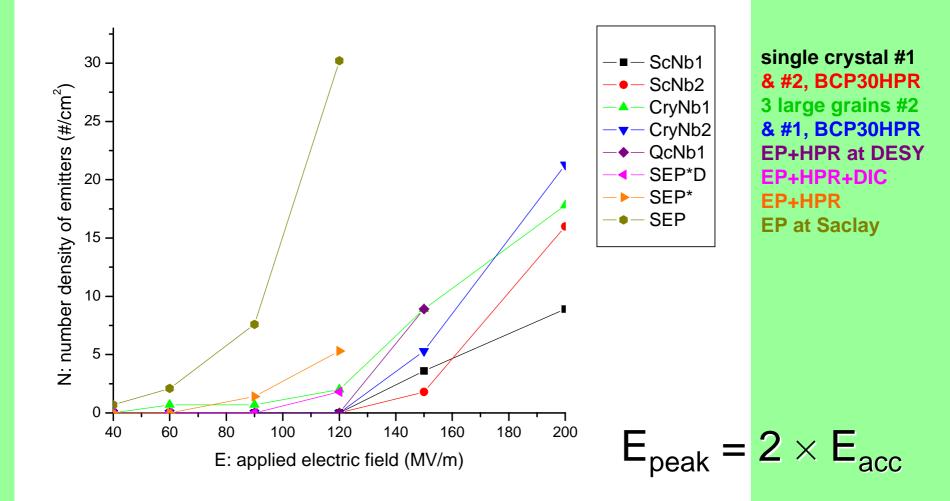


no emission @ 120MV/m 2 emitters @ 150MV/m 5 emitters @ 200MV/m ⇒ best FE performance of all Nb samples yet



Bergische Universität Wuppertal

Emitter statistics for various types of Nb samples



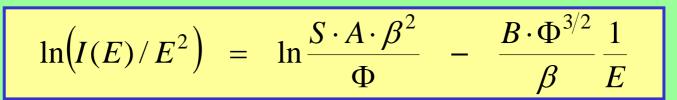
Systematically reduced FE by EP+HPR, DIC and large crystal Nb BCP+HPR of large crystal Nb is probably sufficient

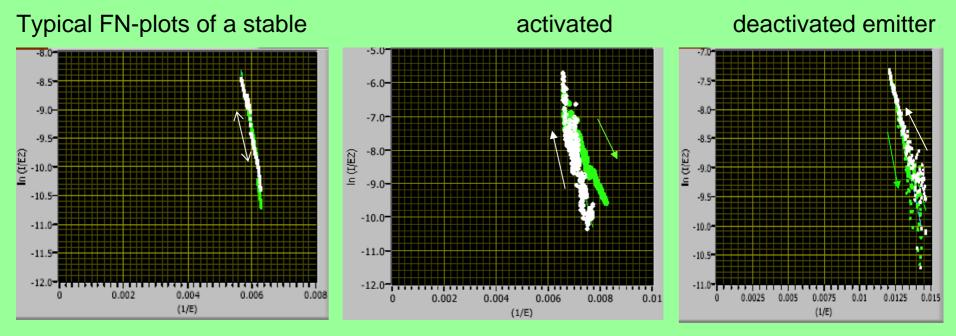






Locally measured I/V-curves and FN-Analysis of emitters





 $\begin{array}{l} {\sf E}_{\rm on}(1~{\rm nA})=76.9~{\rm MV/m}\\ \beta_{\uparrow}=19.3~~{S}_{\uparrow}=1{\times}10^{\text{-}13}\,{\rm m}^2\\ \beta_{\downarrow}=17.9~~{S}_{\downarrow}=5{\times}10^{\text{-}13}\,{\rm m}^2 \end{array}$

 $\begin{array}{l} {\sf E}_{\rm on}(1~{\rm nA}) = 103.3~{\rm MV/m} \\ \beta_{\uparrow} = 17.4 ~~ {\sf S}_{\uparrow} = 1{\times}10^{\text{-}11}\,{\rm m}^2 \\ \beta_{\downarrow} = 31.2 ~~ {\sf S}_{\downarrow} = 3{\times}10^{\text{-}16}\,{\rm m}^2 \end{array}$

 $\begin{array}{l} \mathsf{E}_{on}(1 \text{ nA}) = 54.3 \text{ MV/m} \\ \beta_{\uparrow} = 67.4 \quad \mathsf{S}_{\uparrow} = 2 \times 10^{-17} \text{ m}^2 \\ \beta_{\downarrow} = 61.2 \quad \mathsf{S}_{\downarrow} = 1 \times 10^{-15} \text{ m}^2 \end{array}$

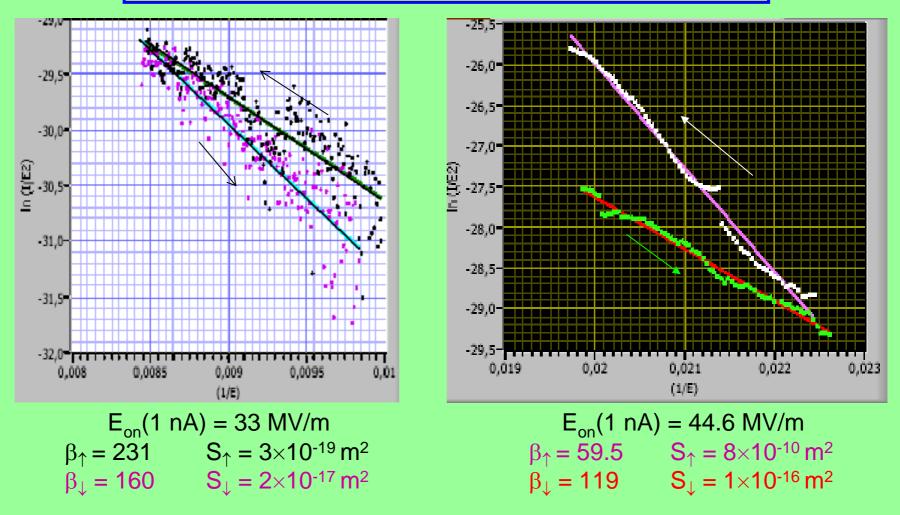
After first processing, most emitters are stable up to 100 nA



Bergische Universität Wuppertal



Current processing of instable emitters



Fluctuations / oscillations most probably caused by adsorbates

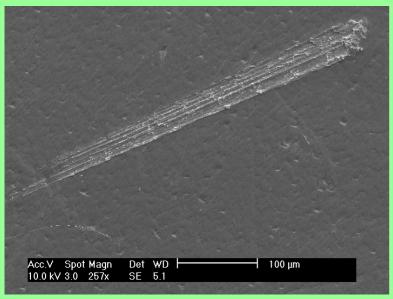
Understanding of instabilities and nature of emitters very difficult



Bergische Universität Wuppertal

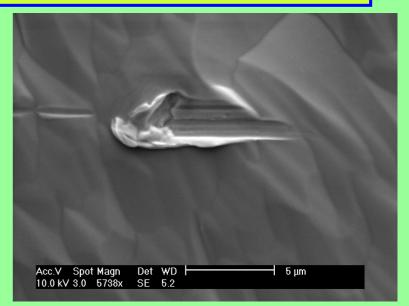


Typical protrusion emitters containing only Nb (+ O?)



E_{on}(2nA) < 60 MV/m ~500 µm long scratch (mishandling of sample)





E_{on}(2nA) = 90 MV/m ~5 μm long groove β = 71, S = 2.3·10⁻⁶ μm²

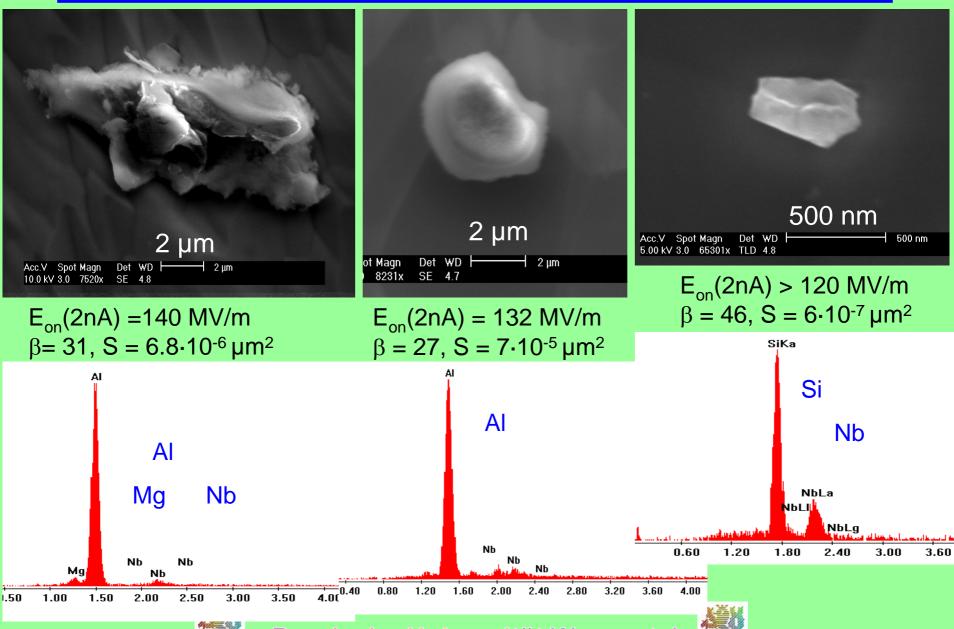
 $E_{on}(2nA) > 140 \text{ MV/m}$ ~1 μm small defect $\beta = 59, S = 7.10^{-8} \mu m^2$



CARE06, Frascati

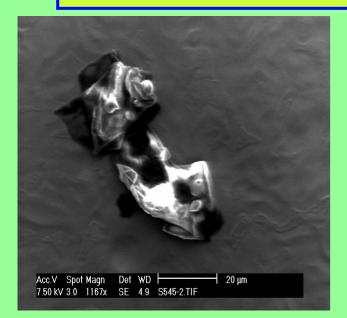


Typical particulate emitters containing impurities



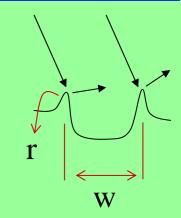
Bergische Universität Wuppertal

Effect of DIC on particulate and protrusion emitters



E_{on}(1nA) = 77 MV/m S particulate removed by DIC





 $\Rightarrow \beta = h/r \sim w/r$ S ~ r²

Protrusion	HPR	HPR+DIC
E _{on} (MV/m)	48.5	103.3
β _↑	166.7	17.4
β _↓	147	31.2
$S_{\uparrow}(m^2)$	1.6 × 10 ⁻²⁰	9.6 × 10 ⁻¹²
$S_{\downarrow}(m^2)$	7.2 × 10 ⁻²⁰	3.3 × 10 ⁻¹⁶

FE of protrusion much reduced by DIC



Bergische Universität Wuppertal

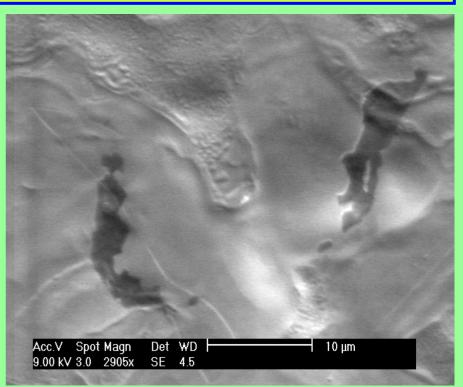


Effect of DIC on a flake-like emitter with exposed edge



emitter of ~ 20 µm size destroyed by DIC remnants emitting at higher E_{on}!

EDX: no foreign element detected (probably oxide of Nb)



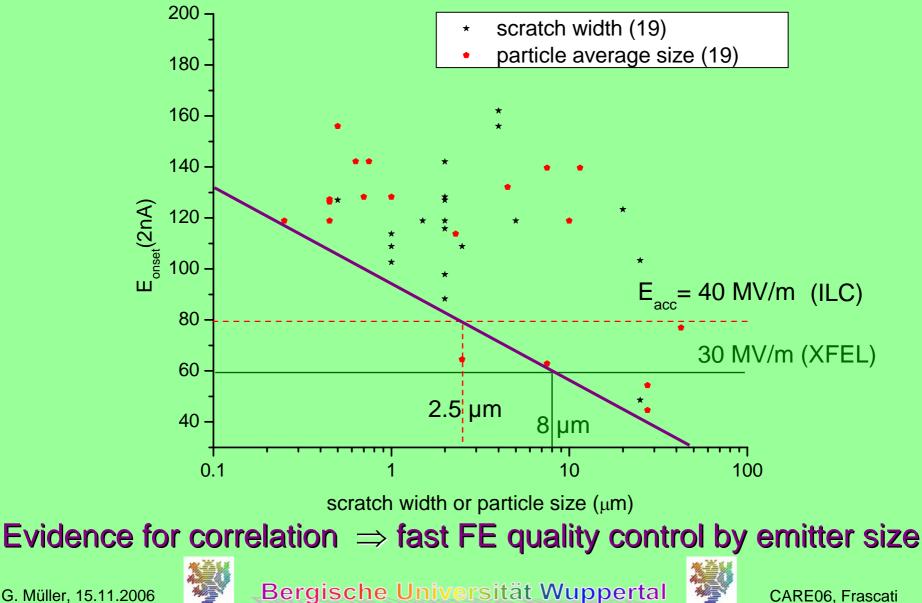
emitter	HPR	HPR+DIC
E_{on} (MV/m)	54.3	62.8
β↑	67.4	35.4
β↓	51.2	38.0
$S_{\uparrow}(m^2)$	2×10^{-17}	8.3 × 10 ⁻¹³
$S_{\downarrow}(m^2)$	1.2×10^{-15}	2.4 × 10 ⁻¹³





Correlation between FE onset field and emitter size ?

based on FE measurements and SEM analysis of 38 field emitters



G. Müller, 15.11.2006

Conclusions and outlook!

- <u>Standard EP+HPR Nb sample</u> provides good FE performance no field emission up to $E_{on} = 120 \text{ MV/m} \implies E_{acc} = 60 \text{ MV/m}$
- Large Nb crystal BCP+HPR samples show best FE results
 ⇒ interesting alternative for cavity fabrication !
- Particulates and protrusions identified as relevant emitters
- DIC effectively removes particulates and weakens protrusions
- After first processing, most emitters are stable up to 100 nA
 - \Rightarrow instabilities and nature of emitters challenging !
- Evidence for correlation between onset field and emitter size
 ⇒ fast FE quality control on samples for XFEL !





A. Dangwal, D. Lysenkov and R. Heiderhoff at Univ. Wuppertal

D. Reschke, W. & X. Singer, A. Matheisen and D. Proch at DESY

D. Werner at Fraunhofer IPA Stuttgart

C. Antoine and A. Aspart at CEA Saclay

